

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Priority Application Serial No. 09/449,025
Priority Filing Date November 24, 1999
Inventor..... Shozo Nagano et al.
Assignee..... Honeywell International, Inc.
Priority Group Art Unit 1775
Examiner Unknown
Attorney's Docket No. 30-5000-(4015)-Div2
Title: Physical Vapor Deposition Targets

PRELIMINARY AMENDMENT

To: Box Patent Application
Assistant Commissioner for Patents
Washington, D.C. 20231

From: Mark S. Matkin (Tel. 509-624-4276; Fax 509-838-3424)
Wells, St. John, Roberts, Gregory & Matkin P.S.
601 West First Avenue, Suite 1300
Spokane, WA 99201-3817

Sir:

Please enter the following amendments prior to examining the above-identified application.

AMENDMENTS

In the Title

Please replace the title with the following: --PHYSICAL VAPOR
DEPOSITION TARGETS.--

In The Specification

At page 1 before the "Technical Field" section, please insert the following:

--RELATED PATENT DATA

This patent resulted from a divisional application of U.S. Patent Application Serial No. 09/449,025, filed November 24, 1999, entitled "Physical

EL465854335US

Vapor Deposition Targets, Conductive Integrated Circuit Metal Alloy Interconnects, Electroplating Anodes, and Metal Alloys For Use as a Conductive Interconnection in an Integrated Circuit”, naming Shozo Nagano, Hinrich Hargarter, Jianxing Li and Jane Buehler as inventors, the disclosure of which is incorporated by reference.--

In the Claims


Cancel claims 1-16 and 21-59 without prejudice.

REMARKS

This application is a divisional application of U.S. Patent Application Serial No. 09/449,025. Original claims 1-16 and 21-59 have been canceled without prejudice. Claims 17-20 remain in the application for consideration.

Respectfully submitted,

Dated: 2-13-01

By: 
Mark S. Matkin
Reg. No. 32,268

RECEIVED